

DISCUSSION OF THE AMENDMENT

Claim 1 has been amended by changing “obtainable” to --obtained--. Claim 7 has been amended by replacing “and” with --or--, to clarify that the process is applicable to either organic or inorganic materials. Claim 8 has been amended by deleting “including printing inks” since the deleted term is necessarily included within the term “inks”; by replacing “and” with --or--, since the process is applicable to any of the recited applications; and “the” has been replaced with --a-- before “liquid phase” for antecedent basis purposes.

New Claim 9 has been added. Claim 9 is supported in the specification at page 2, lines 35 and 38.

No new matter is believed to have been added by the above amendment. Claims 1-9 are now pending in the application.

REMARKS

The provisional rejection of Claims 1-8 under the judicially created doctrine of obviousness-type double patenting over Claims 1-10 over co-pending Application No. 10/501,343 (co-pending application), is respectfully traversed.

The claims of the co-pending application recite the presence of an anionic surface-active additive. It would not have been obvious to exclude such an additive in the invention of the co-pending application, since it is recited therein as an essential constituent and there is no suggestion in the claims therein or in any other prior art to do so.

Accordingly, it is respectfully requested that the rejection be withdrawn.

The rejection of Claim 1 under 35 U.S.C. § 112, second paragraph, is respectfully traversed. Indeed, the rejection is now moot in view of the above-discussed amendment. Accordingly, it is respectfully requested that it be withdrawn.

All of the presently-pending claims in this application are now believed to be in immediate condition for allowance. Accordingly, the Examiner is respectfully requested to pass this application to issue.

Respectfully submitted,

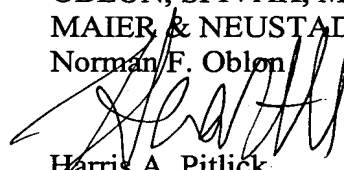
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